

## Overview



- GaN Systems provides RC thermal models allowing customers to perform detailed thermal simulation using SPICE
- Models are created based on FEA thermal simulation and have been verified by GaN Systems
- The Cauer model has been chosen allowing customers to extend the thermal model to their system by including interface material and heat sinks
- The RC thermal models of GaN Systems' devices are available in the datasheets.



- ☐ RC network definition
- ☐ GaNPX® package RC model structure
- ☐ How to use the GaNPX® package RC model in a SPICE simulation
- SPICE simulation examples

# RC network definition



## Thermal network

- Thermal resistance (R<sub>θ</sub>)
- Thermal capacitance (C<sub>θ</sub>)
- Time dependent temperature distribution

### **Analogy between Electrical and Thermal Parameters**

Electrical Parameters	Thermal Parameters
Voltage V (V)	Temperature T (°C)
Current I (A)	Power P (W)
Resistance R (Ω)	Thermal resistance R <sub>0</sub> (°C/W)
Capacitance C (F)	Thermal capacitance $C_{\theta}$ (W·s/°C)

### Equations for calculating $R_{\theta}$ and $C_{\theta}$ :

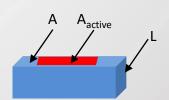
• 
$$R_{\theta} = L/(k \cdot A)$$
 (1)

• 
$$R_{\theta} = L/(k \cdot A_{active})$$
 (2)

• 
$$R_{\theta} = \Delta T/P$$
 (3)

• 
$$C_{\rho} = C_{\rho} \cdot \rho \cdot L \cdot A$$
 (4)

• 
$$C_{\theta} = C_{P} \cdot \rho \cdot L \cdot A_{active}$$
 (5)



#### where:

L - layer thickness (m)

k - thermal conductivity (W/m·K)

A – layer area (m<sup>2</sup>)

A<sub>active</sub> – device active area (m<sup>2</sup>)

T – temperature (°C)

C<sub>P</sub> - pressure specific heat capacity (W·s/kg·K)

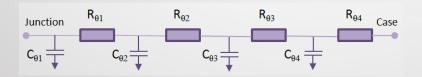
 $\rho$  – density (kg/m<sup>3</sup>)

# Cauer and Foster RC network



#### **Cauer Model**

- Cauer RC network is based on the physical property and packaging structure
- The RC elements are assigned to the package layers



#### Pros:

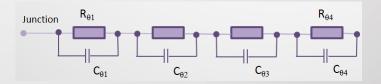
- Cauer RC model reflects the real, physical setup of the device
- Allows to add extra  $R_{\theta}$  and  $C_{\theta}$  to simulate the Thermal Interface Material (TIM) or Heatsink

#### Cons:

- · Detailed thermal analysis using FEM
- Challenge to extract the thermal capacitance

### **Foster Model**

- Foster thermal model is not based on the physical property and packaging structure
- $R_{\theta}$  and  $C_{\theta}$  are curve-fitting parameters



#### Pros:

- Can be extracted from the datasheet transient respond curve
- Can be extracted form a measured heating or cooling curves

#### Cons:

- · Valid only for measured conditions
- Adding extra resistance and capacitance requires a new curve fitting



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# GaNPX® package Junction-to-Case thermal resistance



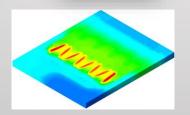
- The detailed steady state and transient thermal analysis were conducted using a 3D heat transfer software with Computational Fluid Dynamics (CFD) capabilities: ElectroFlo and ANSYS Icepack
- During the steady state analysis the device junction-to-case thermal resistance was obtained

#### 650 V Devices

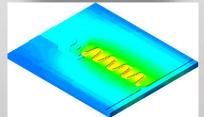










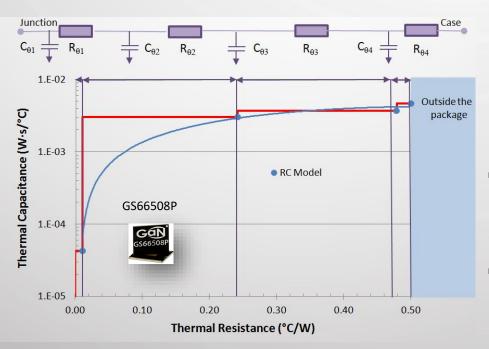


MPN	R <sub>OJC</sub> (°C/W)
GS66502B	2.0
GS66504B	1.0
GS66508B	0.5
GS66508P	0.5

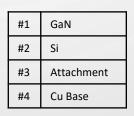
# GaNPX® package RC model structure

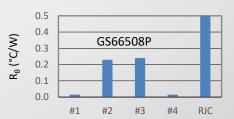


## The Cauer model was chosen for all GaN Systems transistors



The GaN<sub>P</sub>x® package consists of 4 layers:





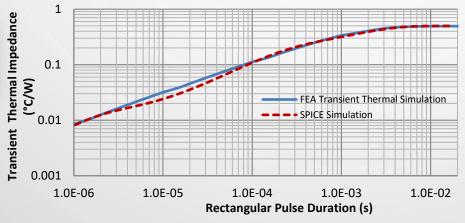
- Layer thermal resistance was derived from the thermal simulation and calculated using the equation (3):
  - $R_{\theta 1} = \Delta T/P = (T_J T_1)/P$
- Layer thermal capacitance was calculated using the active area of the device (equation (5)):

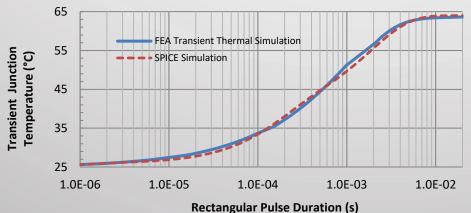
• 
$$C_{\theta 1} = C_{P1} \cdot \rho_1 \cdot L_1 \cdot A_{active}$$

# Thermal and SPICE simulation comparison







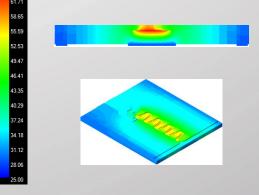


**GS66508P Cauer RC model** 

	R <sub>θ</sub> (°C/W)	C <sub>θ</sub> (W·s/°C)
#1	0.015	8.0E-05
#2	0.23	7.4E-04
#3	0.24	6.5E-03
#4	0.015	2.0E-03

#### **Boundary Condition:**

- Power P = 78 W
- $T_{case} = 25 \, ^{\circ}C$



Good agreement between transient thermal simulation and SPICE simulation has been achieved



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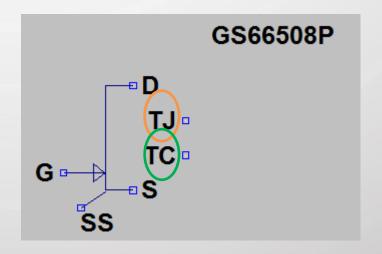
# How to use GaN<sub>PX®</sub> package RC model in a SPICE simulation



### **SPICE Netlist in .lib File:**

Rth\_1 T11 TJ {0.011}
Cth\_1 0 TJ {4.25e-5}
Rth\_2 T22 T11 {0.231}
Cth\_2 0 T11 {2.96e-3}
Rth\_3 T33 T22 {0.237}
Cth\_3 0 T22 {6.65e-4}
Rth\_4 TC T33 {0.021}
Cth 4 0 T33 {1.01e-3}

## **SPICE Symbol:**



#### In the SPICE Schematics:

- Connect T<sub>C</sub> to a voltage equal to the case temperature
- Read V(T<sub>1</sub>) to measure the junction temperature



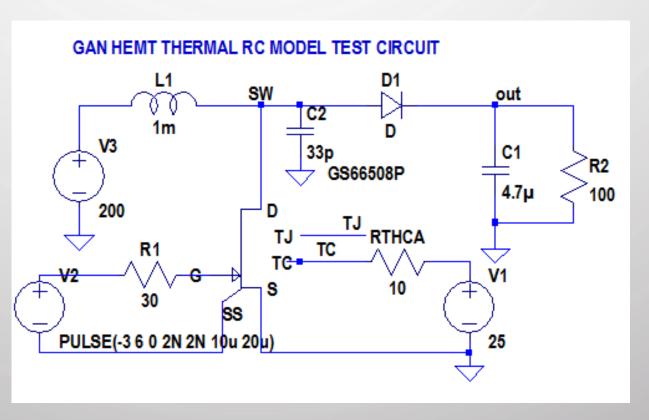
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# SPICE simulation examples



## A simple boost converter circuit was used to verify the functionality of RC thermal model

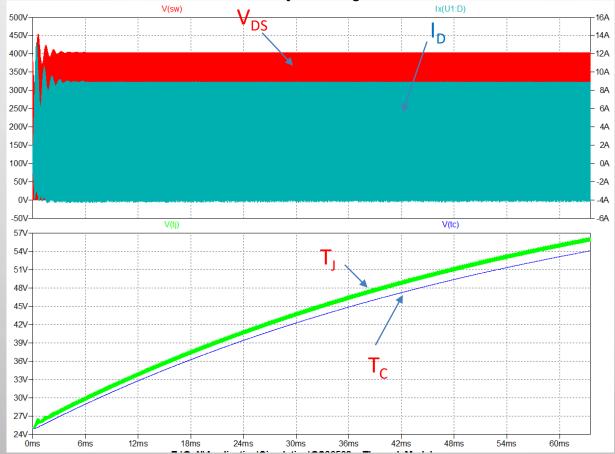
- 200 400 V, I<sub>out</sub> = 4 A
- D = 0.5,  $F_{sw}$  = 50 kHz
- $T_A = 25 \, ^{\circ}C$
- R<sub>THCA</sub> = 10 °C/W
- Monitor T<sub>J</sub>, T<sub>C</sub>



# SPICE simulation examples - waveforms



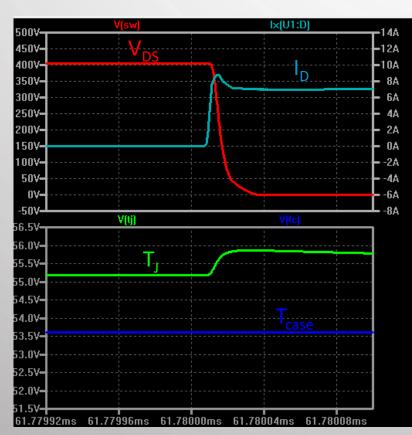
Transient thermal simulation showing T<sub>J</sub> and T<sub>C</sub> time constant for first 70ms



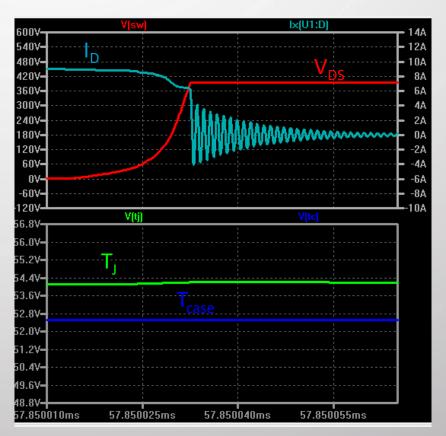
# SPICE simulation examples – Switching transient



### Thermal simulation – Turn-on



### Thermal simulation – Turn-off







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